Magnetostrictive Thin Film Galfenol for MEMS Applications
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- Galfenol-coated Si$_3$N$_4$ double-clamped cantilevers
  - Beams were magnetically actuated
  - Applications will include microvalves, micropumps, MEMS sensors and actuators

- Mechanical Properties
  - First to measure hardness (5 – 9 GPa) and Young’s Modulus (136 - 187 GPa) of Galfenol thin films
  - Young’s Modulus of thin films is higher than bulk values

- Magnetostriction
  - Measured magnetostriction up to 163 ppm
  - Double peak trend of magnetostriction versus %Ga is similar to bulk Galfenol


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